

PROCEEDINGS OF SPIE

*Photonics and Optoelectronics
Meetings (POEM) 2009*

Optical Storage and New Storage Technologies

**Masud Mansuripur
Changsheng Xie
Xiangshui Miao**
Editors

**8–10 August 2009
Wuhan, China**

Organized by
Wuhan National Laboratory for Optoelectronics (China)

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Published by
SPIE

Volume 7517

Proceedings of SPIE, 0277-786X, v. 7517

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Please use the following format to cite material from this book:

Author(s), "Title of Paper," in *Photonics and Optoelectronics Meetings (POEM) 2009: Optical Storage and New Storage Technologies*, edited by Masud Mansuripur, Changsheng Xie, Xiangshui Miao, Proceedings of SPIE Vol. 7517 (SPIE, Bellingham, WA, 2009) Article CID Number.

ISSN 0277-786X

ISBN 9780819479068

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA

Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445

SPIE.org

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